

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: IMAI, Genji

Serial No.: 09/976,279

Filed: October 15, 2001

Group Art Unit: 1752

Examiner: Yvette C. Thornton

P.T.O. Confirmation No.: 1120

For. NEGATIVE PHOTOSENSITIVE RESIN COMPOSITION, NEGATIVE PHOTOSENSITIVE DRY FILM AND METHOD OF FORMING PATTERN

PETITION FOR EXTENSION OF TIME

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

December 16, 2003

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated July 16, 2003 for two months from October 16, 2003, to December 16, 2003.

Attached please find a check in the amount of \$420.00 to cover the cost of the extension for a large entity. In the event that any additional fees are due in connection with this paper, please charge our Deposit Account No. 01-2340.

Respectfully submitted,

ARMSTRONG, KRATZ QUINTOS, HANSON & BROOKS, LLP

Daniel A. Geselowitz, Ph.D. Agent for Applicant

Reg. No. 42,573

DAG/plb Atty. Docket No. **011382** Suite 1000 1725 K Street, N.W. Washington, D.C. 20006 (202) 659-2930

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PATENT TRADEMARK OFFICE